TVENTER TRADENTATION S. Cooper

Title:

Physical Vapor Deposition Components and Methods of Formation

Assignee:

Micron Technology, Inc.

Docket No.

H0001190 (4016)

INFORMATION DISCLOSURE STATEMENT

References - See Attached Form PTO-1449

The attached form PTO-1449 is submitted in compliance with 37 CFR § 1.56. Copies of the cited art are included. No admission is made regarding whether all the submitted references are prior art.

Respectfully submitted,

Datad:

13 Jan 2005

Attorney:

James(ᡛ, Lake

Reg. No. 44,854



Form PTO-1449			U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE					ATTY. DOCKET NO. H0001190 (4016)			SERIAL NO. 09/699,897		
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